COURSE GUIDE - short form

Academic year 2018-2019

Course name ¹	Vacuum deposition techniques II				Cour	ode 1 MATAE DA 06			
Course type ²	DS	Category ³	DI	Year of study	٧	Semester	2	Number of credit points	6

Faculty	Materials Science and Engineering		Number of teaching and learning hours ⁴						
Field	Materials engineering	Total	L	Т	LB	Р	IS		
Specialization	Specialization Advanced materials and experimental analysis techniques		28		14				

Pre-requisites from the	Compulsory	-
curriculum ⁵	Recommended	Vacuum deposition techniques I

General objective ⁶	Acquiring and appropriate use of concepts and methods of making thin films deposited in vacuum
Specific objectives ⁷	Work Skills Training facility vacuum deposition, magnetron booked and evaporation; Gaining theoretical and practical methods, procedures and devices usual deposition of thin films; Gaining theoretical and practical methods and means of characterization of thin films deposited in vacuum; Identify applications of thin layers deposited by physical methods;
Course description ⁸	Methods, procedures and devices in vacuum thermal evaporation deposition; Methods, procedures and devices Sputter deposition; Ion plating deposition methods; Methods for chemical vapor deposition at low pressure; Monitoring and control of thin film vacuum deposition; Methods and means of surface analysis to determine the composition deposited layers; Methods and means for determining the structure of thin films deposited in vacuum; Methods and means for determining the thickness of thin films deposited in vacuum; Methods and means for determining adherence deposited layers; Methods and means for determining the corrosion resistance of the deposited layers; Applications of thin films deposited in vacuum by means of physical, chemical and physicochemical;

	Sche- dule ⁹	Percentage in the final grade (minimum grade) ¹⁰			
A. Final	Class tests along the semester	20%	Week 8-10		
assessment form ¹¹ :	Home works	%	-	700/ (mainima.um	
IOIIII .	Other activities	%	-	70% (minimum	
Exam / Colloquium	Examination procedures and conditions: Probe 1: Three subjects with open questions. Working time 100 minutes	50% (mini- mum 5)		5)	
B. Seminar Activity during seminar				% (minimum 5)	
C. Laboratory Activity during laboratory				30% (minimum 5)	
D. Project Activity during project				% (minimum 5)	

Course organizer	Ioan Gabriel SANDU	
Teaching assistants	Ioan Gabriel SANDU	

 $^{^1\}text{Course}$ name from the curriculum 2 DF – fundamental, DID – in the field, DS – specialty, DC – complementary (from the curriculum)

According to 4.1 – Pre-requisites - from the Course guide – extended form

⁶ According to 7.1 from the Course guide – extended form

According to 7.2 from the Course guide – extended form

⁸ Short description of the course, according to point 8 from the Course guide – extended form

A minimum grade might be imposed for some assessment stages

11 Exam or colloquium

 $^{^3}$ DI – imposed, DO –optional, DL – facultative (from the curriculum) 4 Points 3.8, 3.5, 3.6a,b,c, 3.7 from the Course guide – extended form (L-lecture, T-tutorial, LB-laboratory works, Pproject, IS-individual study)

 $^{^{9}}$ For continuous assessment: weeks 1-14, for final assessment – colloquium: week 14, for final assessment-exam: exam period